

Form 1449 (Modified)

Information Disclosure Statement By Applicant

(Use Several Sheets if Necessary)

Atty Docket No. SUN1P834

Applicant: SOKOLOV et al.

Filing Date 06/20/01

Application No.: 09/886,536

Group 2123-2175

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U.S. Patent Documents

Examiner Initial	No.	Patent No.	Date	Patentee	Class	Sub-Class	Filing Date

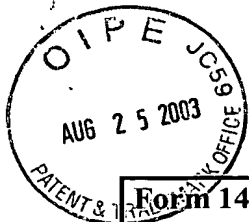
Foreign Patent or Published Foreign Patent Application

Examiner Initial	No.	Document No.	Publication Date	Country or Patent Office	Class	Sub-class	Translation	
							Yes	No

Other Documents

Examiner Initial	No.	Author, Title, Date, Place (e.g. Journal) of Publication
Am	1	Lindholm et al, "The Java™ Virtual Machine Specification", (Sept, 1996), Sun Microsystems, Inc., Chapters 1-10 (173 pp.)
Examiner	Date Considered	
	01-20-04	

Examiner: Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.



Form 1449 (Modified) Information Disclosure Statement By Applicant (Use Several Sheets if Necessary)	Atty Docket No. SUN1P834	Application No.: 09/886,536
	Applicant: Sokolov and Wallman	
	Filing Date June 20, 2001	Group 2123 2175

U.S. Patent Documents

Examiner Initial	No.	Patent No.	Date	Patentee	Class	Sub-class	Filing Date
<i>AM</i>	A	6,093,216	7/25/2000	Adl-Tabatabai et al.	<i>77</i>	<i>128</i>	<i>—</i>
	B						
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Foreign Patent or Published Foreign Patent Application

Examiner Initial	No.	Document No.	Publication Date	Country or Patent Office	Class	Sub-class	Translation	
							Yes	No
	J							
	K							
	L							
	M							
	N							

Other Documents

Examiner Initial	No.	Author, Title, Date, Place (e.g. Journal) of Publication
	O	
	P	
	Q	
Examiner	<i>[Signature]</i> Date Considered <i>01-20-04</i>	

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